

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Hiroshi TAKANASHI et al.

Serial No. 09/262,077

Filed March 4, 1999



Docket No. 01497/FP/TOK-16-US/YH

Group Art Unit 1752

Examiner S. Lee

NEGATIVE-WORKING PHOTOSENSITIVE :
RESIN COMPOSITION AND PHOTO- :
SENSITIVE RESIN PLATE USING THE SAME :

**THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEE FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975.**

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents
Washington, DC 20231

Sir:

Petition hereby is made for a third month extension of time to respond to the communication of
January 3, 2000.

The fee of \$490.00 is

- (X) submitted herewith. Attention is directed to the fact that the fee of \$380.00 for a two month extension of time was paid June 5, 2000.
- () to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.
- () Small entity status of this application is established by the verified statement under 37 CFR 1.9 and 1.27 which
 - () is enclosed.
 - () has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By


Matthew Jacob

Registration No. 25,154

Attorney for Applicants

07/03/2000 SLUANG1 00000063 09262077

01 FC:117

490.00 DP

MJ/pjm

Washington, D.C.

Telephone (202) 721-8200

June 30, 2000

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